

Exchange bias dependence in gradually patterned antiferromagnet

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Exchange bias is a phenomenon associated with the exchange interaction at the antiferromagnetic/ferromagnetic (AF/FM) interface. The exchange coupling between dissimilar materials shifts the center of the hysteresis loops along the external field axis by an amount known as exchange bias field (H_{EB}). It is generally assumed that H_{EB} decreases as FM thickness (t_{FM}) increases following a dependence of $1/t_{FM}$ [1]. In this work we investigate the dependence of FM layer thickness on the exchange bias field in continuous and patterned FeF_2/FM ($FM = Ni, FeNi$) bilayers. The AF layer was gradually etched in patterned samples using a photolithography mask (Figure 1). t_{FM} varies from 3 to 100 nm whilst the AF thickness under the FM layer was kept constant at 70 nm. Experimental measurements reveal that H_{EB} vs t_{FM} largely deviates from the dependence of $1/t_{FM}$. A theoretical model considering spring-like domain walls through the FM layer [2,3] and a finite AF anisotropy [4] is taken into account to explain the results.

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Figures

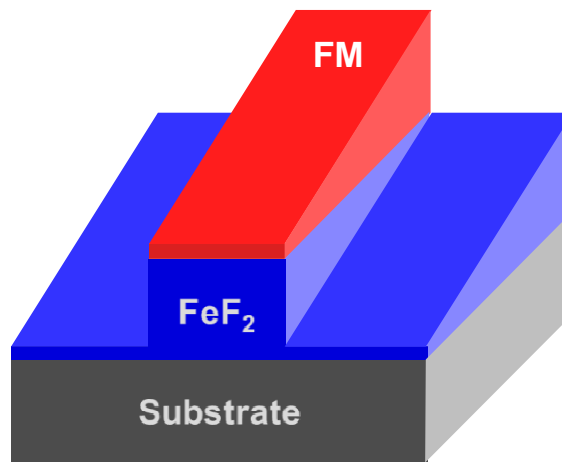


Figure 1. A wedged FeF₂/FM sample patterned into stripes